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Wentao Wang, Fude Liu, Chor Man Lau, Lei Wang, Guandong Yang, Dawei Zheng, and Zhigang Li

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Field-effect BaTiO$_3$-Si solar cells

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Conventional solar cells make use of the spatial variation in electronic environment due to junctions for charge separation. We investigated field-effect BaTiO$_3$-Si solar cells that utilize the bound surface charges of BaTiO$_3$ to separate charge carriers in silicon. Rectifying behavior and photovoltaic effect were observed on cells with forward polarization. Theoretical simulation indicated that the induced electric field due to BaTiO$_3$ polarization could extend into the silicon layer, which is consistent with experimental observations. In addition, adjusting relevant parameters may optimize the electric field distribution. The cells are promising in terms of material selection, device design, and fabrication.

Photovoltaic devices are generally developed for optimizing three key steps for charge carriers: generation, separation, and transport. Conventional solar cells make use of the spatial variation in electronic environment due to junctions for charge separation, and the PN junction structure is a classic model of this concept. However, this kind of structure has limitations on materials selection and device fabrication to form a workable junction due to issues such as lattice mismatch, doping, and band alignment. Moreover, either homo-junctions or hetero-junctions inevitably introduce defect states that act as recombination or trapping centers for charge carriers. In contrast, ferroelectric-based photovoltaic cells, which usually consist of a ferroelectric layer sandwiched between two electrode plates, can avoid aforementioned issues and, thus, have attracted considerable attention recently. These cells have an internal electric field throughout the bulk region originating from electrical polarizations that are not completely compensated by screening charges. Consequently, a fascinating charge separation mechanism exists in these cells, and even the light-induced open circuit voltage ($V_{oc}$) can be greater than the band gap. However, ferroelectric materials are, in general, highly insulating because of their large band gaps, which limits the absorption of sunlight. Thus, ferroelectrics should be coupled with semiconductors in order to achieve photovoltaic cells with good performance.

In this work, we investigated a type of solar cells that combine a ferroelectric (BaTiO$_3$) and a semiconductor (Si). The cells avoid the PN junction structure and utilize the bound surface charges of BaTiO$_3$ to separate photon-generated charge carriers in Si. This structure has an interesting feature that free charge carriers and fixed charge carriers are physically separated from each other. Thus, it is promising in preparing solar cells because of its more flexibility in material selection, device design, and fabrication.

The schematic of device structure and a real cell are shown in Fig. 1, respectively. As illustrated in Fig. 1(a), the cell consists of a ferroelectric layer, a semiconductor layer, a pair of poling electrodes ($P$-electrodes), and a pair of working electrodes (anode and cathode). The $P$-electrodes patterns are aligned well with those of anode and cathode, respectively. Anode and cathode collect electrons and holes, respectively, which are photon generated in the semiconductor layer, under the influence of the external field due to ferroelectric polarizations; electrons then flow through the external circuit to do work on the load (R) and finally recombine with holes at the cathode. Note that neighboring regions in the ferroelectric layer are polarized in opposite directions such that negative and positive bound surface charges are accumulated to different electrodes in a fashion as shown in the figure. To fabricate a real cell (Fig. 1(b)), silicon and BaTiO$_3$ were chosen as the semiconductor absorber and ferroelectric layer, respectively, because of mature technologies. A piece of $p$-type single crystalline Si wafer with thickness of 280 $\mu$m and size of $20 \times 20 \text{mm}^2$ was cleaned with the RCA ($= \text{Radio Corporation of America}$) clean. Due to their different work functions, Ti and Au were chosen for anode and cathode, respectively, that were deposited on Si with sputtering using a shadow mask. BaTiO$_3$ was then spin coated on Si with the sol-gel method using a precursor solution (0.40 mol/l) based on Ba(CH$_3$COO)$_2$, Ti(OCC$_2$H$_5$)$_4$, polyvinylpyrrolidone (PVP)-360000, H$_2$O, CH$_3$COOH, and C$_2$H$_5$OH.$^6$ After each spin coating step, the sample was dried at 350°C for 10 min before proceeding to next step; the coating may be repeated several times depending on the film thickness required. Then, the sample was stepwise heated at 300°C and 500°C for 10 min, respectively, and finally at 700°C for 15 min to achieve full crystallization of BaTiO$_3$. $P$-electrodes of Ag were deposited on BaTiO$_3$ with thermal evaporation. Post annealing at 450°C for 15 min was then conducted to form good metal contacts. Finally, the sample was wired out with Ag paste and metal wire, and then covered with epoxy and glass for insulating. The poling was conducted at 180°C and then at room temperature for 10 min, respectively. During the poling process, the silver $P$-electrodes were grounded, and 18 V was applied on the Au cathode and −18 V on the Ti anode simultaneously, which is defined as forward polarization.

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(see Fig. 1(a)); it is called reverse polarization when the external poling voltage are swapped between anode and cathode. The electrical characterization was carried out with a standard solar simulator (ABET Sun 2000 coupled with Keithley 2602A). All current-voltage (I-V) measurements were conducted by sweeping the voltage from negative to positive. The distribution of the induced electric field in Si due to the bound surface charges of BaTiO$_3$ was simulated with the finite-element method using the AC/DC Module of COMSOL $^\odot$.

The way of poling on the ferroelectric plays an important role in device performance. Fig. 2 depicts the I-V curves of the before-polarization and reverse-polarization states, respectively, under dark condition. Before polarization, the I-V curve is a straight line with high resistivity. After reverse polarization, the I-V curve in general is still linear but with lower resistivity. So the cell shows Ohmic behavior for both cases. However, after forward polarization, the conduction behavior under dark condition is changed dramatically; a substantial diode rectifying behavior is evident in the corresponding I-V curve (black one in Fig. 3(a)). The rectification ratio is $\sim$220 at $V = \pm 0.5$ V. The diode-like behavior has been constantly observed in all our cells (>20 cells). Therefore, the polarization of BaTiO$_3$ can greatly affect the transport of charge carriers in Si.

Under sunlight illumination at 100 mW/cm$^2$, the I-V curve shifts downward for the forward-polarization state, exhibiting the photovoltaic effect (brown curve in Fig. 3(a)). The corresponding $V_{oc}$ and $I_{sc}$ are $\sim$170 mV and 0.035 $\mu$A, respectively. We also studied the time-dependent $I_{sc}$ when the illumination was switched on or off under short-circuit condition (Fig. 3(b)). We see that the photocurrent is generated whenever the cell is exposed to sunlight, and it disappears whenever the illumination is off. Therefore, photon-generated charge carriers in Si can be separated and then collected by anode or cathode. Because the band gap of BaTiO$_3$ is 3.2 eV and the light is shot from the thick Si side, it is reasonable to assume that photon-generated charge carriers in Si mainly contribute to the photovoltaic effect. In addition, there are no initial small spikes of photocurrent, which rule out the pyroelectric effect as well.$^8$

![FIG. 1. Schematic of device structure and real cell. (a) Schematic of device structure (cross-section view; not drawn to scale) and (b) real cell (top-down view from the ferroelectric side).](image)

![FIG. 2. I-V curves of the before-polarization and reverse-polarization states, respectively, under dark condition.](image)

![FIG. 3. Rectifying behavior and photovoltaic effect of the forward-polarization state. (a) I-V curves under dark and illumination conditions, respectively. (b) Time-dependent $I_{sc}$ when the illumination is switched on or off.](image)
We now understand the crucial role played by the forward polarization in the rectifying behavior and photovoltaic effect. To further understand this, it is necessary to know the distribution of the induced electric field in Si due to the bound surface charges of BaTiO₃. Fig. 4(a) represents the simulation model whose geometry parameters are from real cells. The relative permittivity of Si, BaTiO₃, and Ag is 11.9, 9, 290, and 6.9, respectively. The relative permittivity of Ti and Ag is unknown in the literature; we simply took the same value of 6.9 for them too (which is not expected to greatly affect the over picture on electric field distribution). Next, the bound surface charge density was set to be ±0.10 C/m² (typical value) for the polarized BaTiO₃ layer. The simulated electric field distribution in the cell is shown in Fig. 4(b). Also included is the electric field legend that is color-coded for easy viewing. Because the BaTiO₃ layer is very thin compared to the Si layer, it is barely seen in the figure. It is obvious that the induced electric field extends into the Si layer. Overall, the electric field points toward the cathode and points away from the anode, as indicated by black arrows. Thus photon-generated electrons and holes would drift to the anode and cathode, respectively, under the influence of the induced electric field. The current flow direction is then consistent with our experimental results shown in Fig. 3. Note that the electric field is in the order of 10⁶ V/cm, which is much weaker than that of a typical PN junction (in the order of 10³–10⁴ V/cm). In addition, the electric field distribution in the Si layer is not uniform. In particular, the field is relatively stronger in regions (in red) near the electrodes and is relatively weaker in regions (in blue) between cathode and anode. The weak and non-uniform electric field may be one major reason for the poor device performance.

The device performance may be improved through geometry optimization. Fig. 5 shows the simulation of the electric field distribution in a possible optimized cell after adjusting the dimension parameters. We see that in the optimized cell, the electric field in Si is now increased to be in the order of 10³ V/cm, which is comparable to that in a typical PN junction. In addition, its electric field distribution is more uniform. It is then expected that real cells based on the optimized model may have better performance.

It should be pointed out that in our simulation, we have not considered the screening effect of metal electrodes on the bound surface charges of the ferroelectric, which may weaken the induced electric field in the semiconductor.

Transparent conducting oxides (TCO) with less carrier density and longer screening length may be used as electrodes instead to mitigate this problem. In real cells, besides the weak and non-uniform electric field, poor metal contacts with high resistance are another major reason for the poor device performance, in particular, low current, as indicated in Figs. 2 and 3. In addition, we may need to consider other issues such as surface passivation, ionic defects in the ferroelectric, and possible carrier injection between BaTiO₃ and Si. All the aforementioned issues are good points to address in the future work. In this study, however, we focus mainly on the concept demonstration of BaTiO₃-Si cells.

In summary, we investigated field-effect BaTiO₃-Si solar cells in detail with both experimental results and theoretical simulation. Real solar cells showed the rectifying behavior and photovoltaic effect after forward polarization only. Theoretical simulation indicated that the induced electric field due to the BaTiO₃ polarization could extend into the Si layer and then photon-generated carries in Si could be separated and collected for electricity generation. Adjusting relevant parameters such as dimension, materials, and polarization charge density may optimize the electric field distribution for improving device performance. Although we have focused only on BaTiO₃ and Si, the concept introduced herein may be applied to other material systems because of its flexibility in material selection, device design, and fabrication.

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